

| L Number | Hits | Search Text | DB | Time stamp |
|-------------|------|---|-------|---------------------|
| - | 208 | spacer with coat\$ and (445/24 or 313/422 or 313/309) | USPAT | 2003/04/28 15:08 |
| - | 19 | (spacer with coat\$ and (445/24 or 313/422 or 313/309)) and spacer same silicon with (cvd or vapor or DMSDMA or dimethylsilyld\$) | USPAT | 2003/04/28 15:19 |
| - | 0 | (spacer with coat\$ and (445/24 or 313/422 or 313/309)) and spacer same silicon with (cvd or vapor or DMSDMA or dimethylsilyld\$) not ((spacer with coat\$ and (445/24 or 313/422 or 313/309)) and spacer same silicon with (cvd or vapor or DMSDMA or dimethylsilyld\$)) | USPAT | 2003/04/28 15:19 |
| - | 2 | spacer same resist and spacer with (cvd or vapor or DMSDMA or dimethylsilyld\$) and display adj panel | USPAT | 2003/04/28 15:22 |
| - | 0 | spacer same resist and posts with (cvd or vapor or DMSDMA or dimethylsilyld\$) and display adj panel | USPAT | 2003/04/28 15:22 |
| - | 1 | spacer same resist and posts with (cvd or vapor or DMSDMA or dimethylsilyld\$) and display adj panel | USPAT | 2003/04/28 15:24 |
| - | 1 | spacer same photoresist and (posts with (cvd or vapor or DMSDMA or dimethylsilyld\$)) and display adj panel | USPAT | 2003/04/28 15:27 |
| - | 363 | 313/422 and (CDV or vapor or chemical or deposition) | USPAT | 2003/04/28 15:29 |
| - | 210 | (313/422 and (CDV or vapor or chemical or deposition)) and spacer | USPAT | 2003/04/28 15:30 |